Parametric Optical Signal Processing in Silicon Waveguides with Reverse-biased p-i-n Junctions

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Nonlinear platforms for signal processing



Minimum pump power required for a target conversion efficiency

J. Martínez Díaz et al., IPC (2013) ThG1.5.



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Outline

• Motivations

- Silicon waveguides with p-i-n junctions
- Phase insensitive signal processing
 - High-efficiency FWM wavelength conversion
- Phase-sensitive signal processing
 - Regeneration of phase modulated signals
 - Simultaneous wavelength and modulation format conversion
- Summary

Silicon waveguides with p-i-n junction

Avoiding nonlinear loss:

- 1. Operate at wavelengths above 2120 nm
 - no TPA
 - no telecom band operation
- 2. Pulsed pump operation with low repetition frequency
 - not compatible with high bit rate operation
- 3. p-i-n junction across the nonlinear silicon waveguide
 - Sweep the carriers generated by two-photon absorption
 - Reduce effective carriers lifetime
 - \Rightarrow limits the impact of free-carrier absorption

H. Rong et al., Opt. Express 14 (2006) 1182.

- A. C. Turner-Foster et al., Opt. Express 18 (2010) 3582.
- J. R. Ong et al., IEEE Photon. Technol. Lett. 25 (2013) 1699. 6



Fabricated silicon waveguide structure





- Waveguide height: H= 210 nm
- Slab height: s= 50 nm
- Rib width: w= 500 nm
- Covered by 100 nm SiO₂ and 90 nm Si₃N₄
- p-doped region: boron
- 10¹⁸ cm⁻³
- n-doped region: arsenic _
- doped regions spaced 1.2 μm
- higher doped contact regions spaced further away
- Fabricated in a BiCMOS foundry using 258 nm lithography
- 8" wafers with 2 μm buried oxide layer

Silicon waveguides optical properties

Quantity	Value	Unit
Length	4	cm
Loss	1	dB/cm
TPA coeff.	0.5	cm/GW
Nonlinear coeff.	280	W⁻¹⋅m⁻¹
Coupling loss*	4.5	dB/facet

*1D grating couplers with 35 nm bandwidth

Optical properties in line with standard SOI waveguides + p-i-n junction

Record (2012) conversion efficiency





Phase-insensitive Signal Processing



Wavelength conversion bandwidth



Conversion efficiency: output: input/output: $\eta_{LL} = \frac{P_i(L)}{P_s(L)}$ $\eta_{0L} = \frac{P_i(L)}{P_s(0)}$ • 20 dBm pump power

- 0 dBm signal power
- 20 V reverse bias
- Good agreement between measurement and theory for D=-2450 ps/(nm·km)
- 3 dB conversion bandwidth of ~10 nm
- Wider bandwidths achievable after dispersion engineering

A. Gajda et al., Group IV Photonics (2013) FC3.



BER performance for wavelength conversion



Phase-sensitive Signal Processing

Motivations for phase-sensitive processing in waveguides



- Stimulated Brillouin scattering (SBS) limits the amount of pump power that can be coupled in a highly nonlinear fibre (HNLF)
- Classic mitigation technique for parametric amplification:



phase dithering of the pumps

- Not "phase-sensitive friendly" technique
- Other techniques:
 - High-SBS threshold HNLFs \Rightarrow 15 dB/km loss (1st generation)
 - Strained HNLFs \Rightarrow OK as long as dispersion well controlled

Short (but highly nonlinear) waveguides should be relatively immune to SBS

Phase sensitive processing in waveguides

• Periodically-poled lithium niobate waveguides

K. J. Lee et al., Opt. Express 17 (2009) 20393.

B. J. Puttnam et al., IEEE Photon. Technol. Lett. 23 (2011) 426.

T. Umeki, Opt. Express 21 (2013) 12077.

Chalcogenide waveguide

R. Neo et al., Opt. Express 21 (2013) 7926.

- Low TPA, no FCA
- 10 dB phase-sensitive extinction ratio (pulsed pump 38.6 MHz)
- Limited by damage threshold of the waveguide
- Silicon photonic crystal waveguide

Y. Zhang et al., Opt. Lett. 39 (2013) 363.

- 11 dB phase-sensitive extinction ratio (pulsed pump 38.6 MHz)
- Limited by TPA and FCA

Static phase-sensitive investigation



- Phase coherence between pumps and signal ensured by frequency comb generation
- Frequency spacing of 40 GHz between interacting waves

F. Da Ros et al., ECOC (2013) P.2.11.

Evidence of phase-sensitivity in Si







Phase-sensitive regenerator output spectrum



Higher-order sidebands generated

F. Da Ros et al., Opt. Express 22 (2014) 5029.







Phase-sensitive wavelength conversion





Conversion efficiencies of the idlers



90° phase-shifted dependences of the conversion efficiencies of the idlers on the input signal phase

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Summary

- Silicon waveguides with p-i-n junctions have been designed and fabricated with good optical properties
- High-efficiency FWM wavelength conversion demonstrated at 40 Gbit/s
- First demonstration of phase-sensitive processes on-chip with CW pumping
- Complete phase regeneration demonstrated using 4 cm long waveguide

Trade-off silicon photonics compatibility with increased complexity of active removal of carriers

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